NILindustrialday 2025

May 5 and 6, Vienna



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Day 1 – May 5					
CEST 09:00	11:00		Setting up of exhibition		
11:00	12:30		Arrival of participants / registratiom / exhibition / sandwich lunch		
12:30	bmimi, MRT, PR	OFACTOR	Welcome and opening of the NILindustrialday 2025		
Session 1 – Session chair: Jan Stensborg (Stensborg A/S)					
12:40	NILT	Theodor Nielsen	Nano-optics solutions by NIL for consumer electronics applications		
13:00	Dispelix	Mikhail Omelyanovich	Durable, ultralight, high-performance AR waveguides		
13:20	EVG	Patrick Schuster	Status & Perspectives of Nanoimprint Lithography: Focus on sustainable high-volume manufacturing		
13:40	imec	Eleonora Storace	Waveguide displays for Augmented Reality: Enhancing performance through design for manufacturability and advanced lithography		
14:00	micro resist technology	Maria Russew	Recent material innovations for sacrificial and non-sacrificial NIL enabling high performance applications		
14:20			Coffee break / exhibition		
Session 2	- Session chair: '	Vincent Einck (Myrias Opti	cs)		
15:00	IMS CHIPS	Astrit Shohi	Mastering the Master: Nanopatterning beyond binary features		
15:20	PROFACTOR	Michael Mühlberger	Nanoimprinting for polymer-based augemented reality devices		
15:40	IBA Heiligenstadt	Marcus Soter	Nanoimprint Lithography for Medical Devices: Using FluidFM and NIL to improve blood-contacting surfaces		
16:00	SINTEF	Christopher Dirdal	NIL for scalable MEMS-metasurfaces and SERS sensors with applications within medical and environmental sensing		
16:20			Coffee break / exhibition		
Session 3	- Session chair:	Pavel Kulha (PROFACTO	२)		
17:00	Myrias Optics	Vincent Einck	Commercialization of All-Inorganic Direct NIL: Manufacturing and wafer level test		
17:20	SCIL Nanoimprint	Erik Peters	SCIL: tools and materials for direct patterning of advanced nano- optics		
17:40	Nanoscribe	Jochen Zimmer	Two-Photon Grayscale Lithography (2GL) for masters without stitching seams and tilt-related imperfections		
18:00	Snap	Atul Chaudhari	Engineering Functional Materials for Next-Gen AR Optics		
18:20 18:40			Break Departure for social event		
Exhibition:			Gold sponsor:		
EVG Obducat Germanlitho SCIE OF CONSTRUCTION OF CONSTRUCTUOES OF					
STENSBORG					
Bronze spo	onsors:	op imec	an event with financial climate contribution In cooperation with ClimatePartner Federal Ministry Innovation, Mobility and Infrastructure Republic of Austria		
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<u> Day 2 – May 6</u>

08:40

CEST 08:00



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08:40	MRT & PROFACTO	OR	Opening of day 2 of the NILindustrialday 2025		
Session 4 – Session chair: Mirko Lohse (MRT)					
08:50	SUSS MicroTec	Amir Sharghi	From AR to Co-Packaging: a vision for integrated optics		
09:10	Tokyo University of Science	Jun Taniguchi	Fabrication of NIL mold and application technology using silver ink transfer		
09:30	Tekscend Photomasks	Martin Sczyrba	Advanced NIL master manufacturing technologies for XR systems and meta-optics applications		
09:50	SAL	Clement Fleury	8-inch NIL master fabrication for metasurfaces and color filter applications		
10:10	Germanlitho	Ran Ji	Introduction to NIL industrial applications and market trends		
10:30	Joanneum Research	Daniel Borstner	Functional structures in microfluidics devices fabricated by Roll-to- Roll UV-nanoimprint lithography		
10:50			Coffee break / exhibition		
Session 5 – Session chair: Thomas Achleitner (EVG)					
11:30	Scia systems	Tabea Albert	Precision Fabrication of SRG: The role of ion beam processing in AR technology		
11:50	UpNano	Markus Lunzer	Adaptive Resolution 2-Photon Lithography for highly-defined large- area NIL masters		
12:10	Morphotonics	Bram Titulaer	Advancements in mass production of nano and micron structured surfaces using large-area NIL		
12:30	Heidelberg Instruments	Julia Stark	NanoFrazor thermal scanning probe lithography: Nanometer precise grayscale patterning for NIL master templates		
12:50	Himax IGI	Glen de Villafranca	High Volume Wafer Scale Optics: From mastering to mass production		
13:10	MRT & PROFACT	OR	Final announcements		
13:20			Lunch / networking		
14:30			End of exhibition and of NILindustrialday 2025		
Exhibition:			Gold sponsor:		
EVG Germanlitho Science Construction					
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Exhibition / arrival of participants / coffee